

United States Patent [19]

Hattori

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[45] Date of Patent: **** Aug. 8, 1989**

[54] DIVING MASK

[75] Inventor: Seiji Hattori, Kanagawa, Japan

[73] Assignee: Dacor Corporation, Northfield, Ill.

[**] Term: 14 Years

[21] Appl. No.: 858,221

[22] Filed: Apr. 28, 1986

[52] U.S. Cl. D29/9; D16/107

[58] Field of Search D16/100-129;
D29/9; 2/12, 13, 15, 426, 431, 432, 436, 439,
440, 442, 444, 446, 452

[56] **References Cited**

U.S. PATENT DOCUMENTS

D. 266,031 9/1982 Sato D16/107
3,605,204 9/1971 Amundsen 2/452

3,800,329 4/1974 Semeia 2/439
4,112,521 9/1978 Uke 2/452
4,564,960 1/1986 Nishiyama 2/452

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[57] **CLAIM**

The ornamental design for a diving mask, as shown and described.

DESCRIPTION

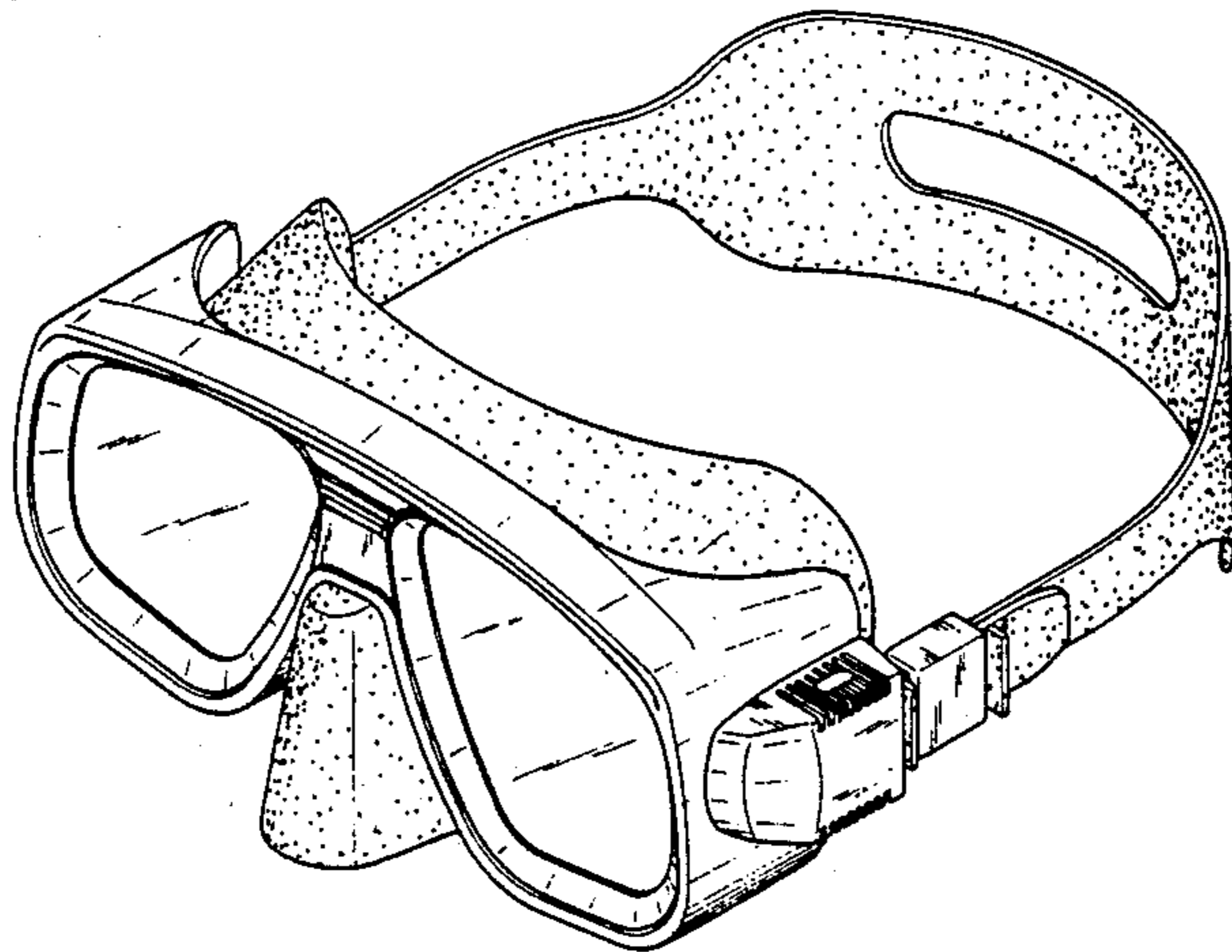
FIG. 1 is a left side perspective view of a diving mask embodying my new design, the opposite side being substantially a mirror image thereof;

FIG. 2 is a front elevational view thereof;

FIG. 3 is a rear elevational view thereof;

FIG. 4 is a top plan view thereof;

FIG. 5 is a bottom plan view thereof.



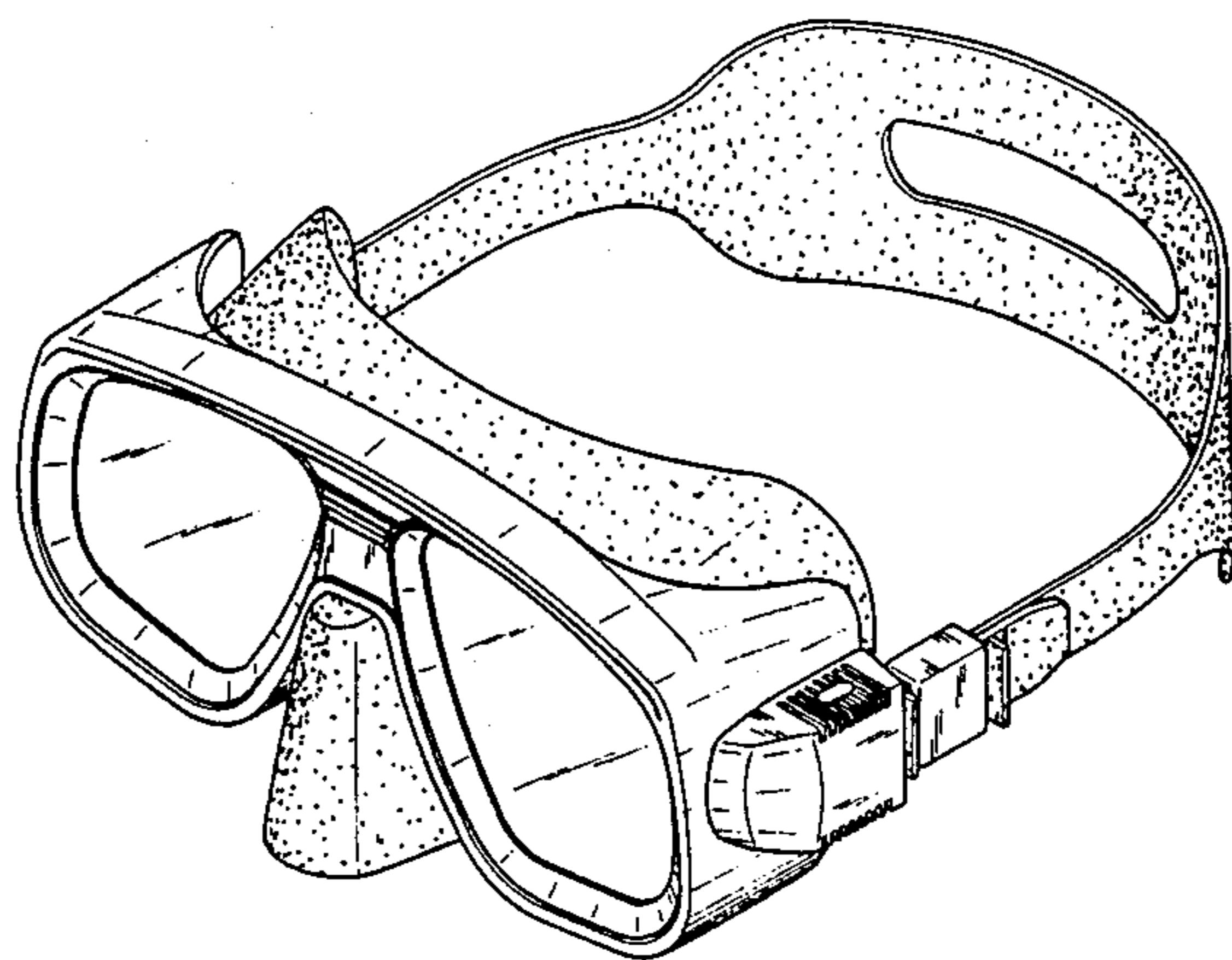


FIG. 1

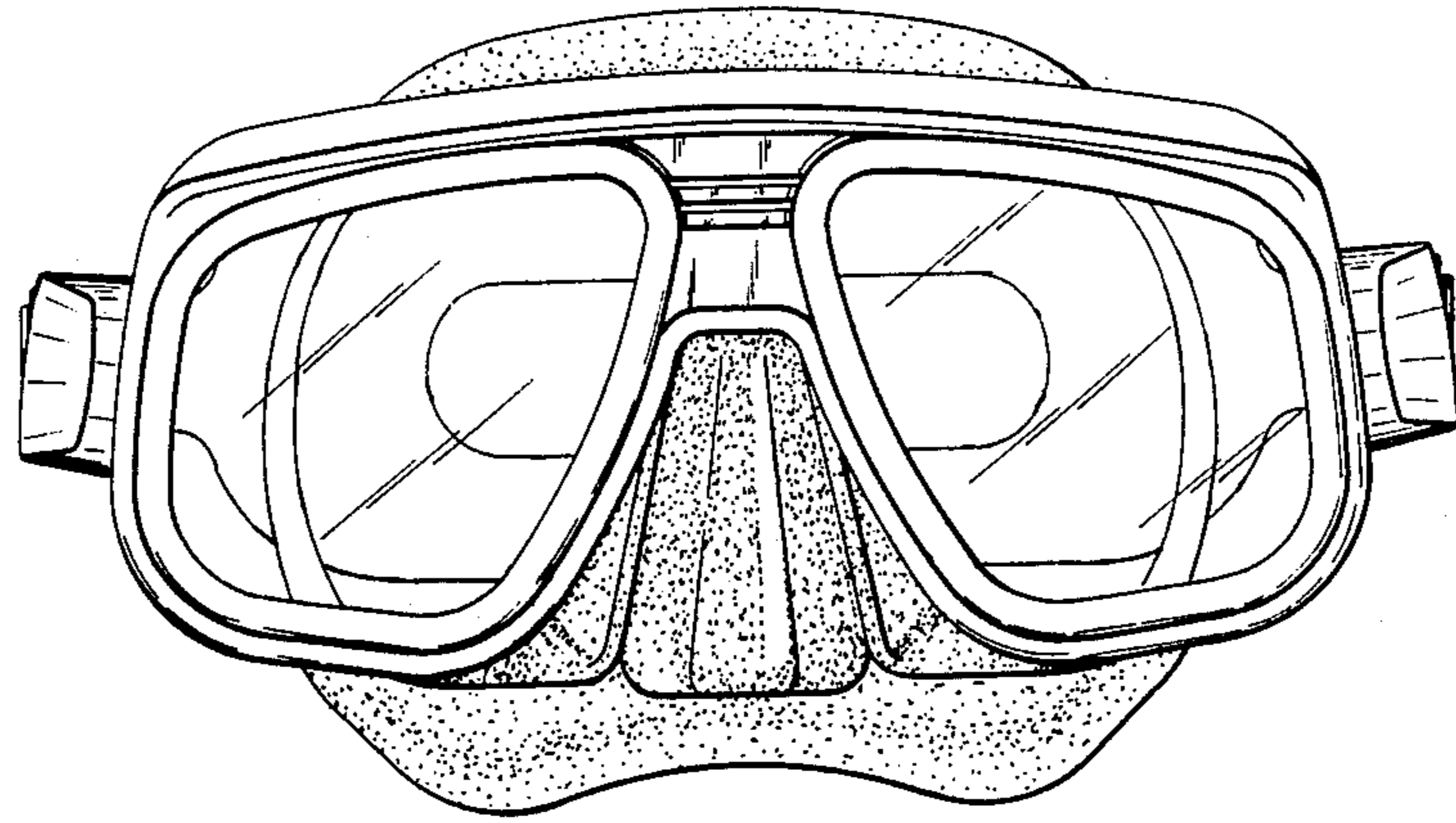


FIG. 2

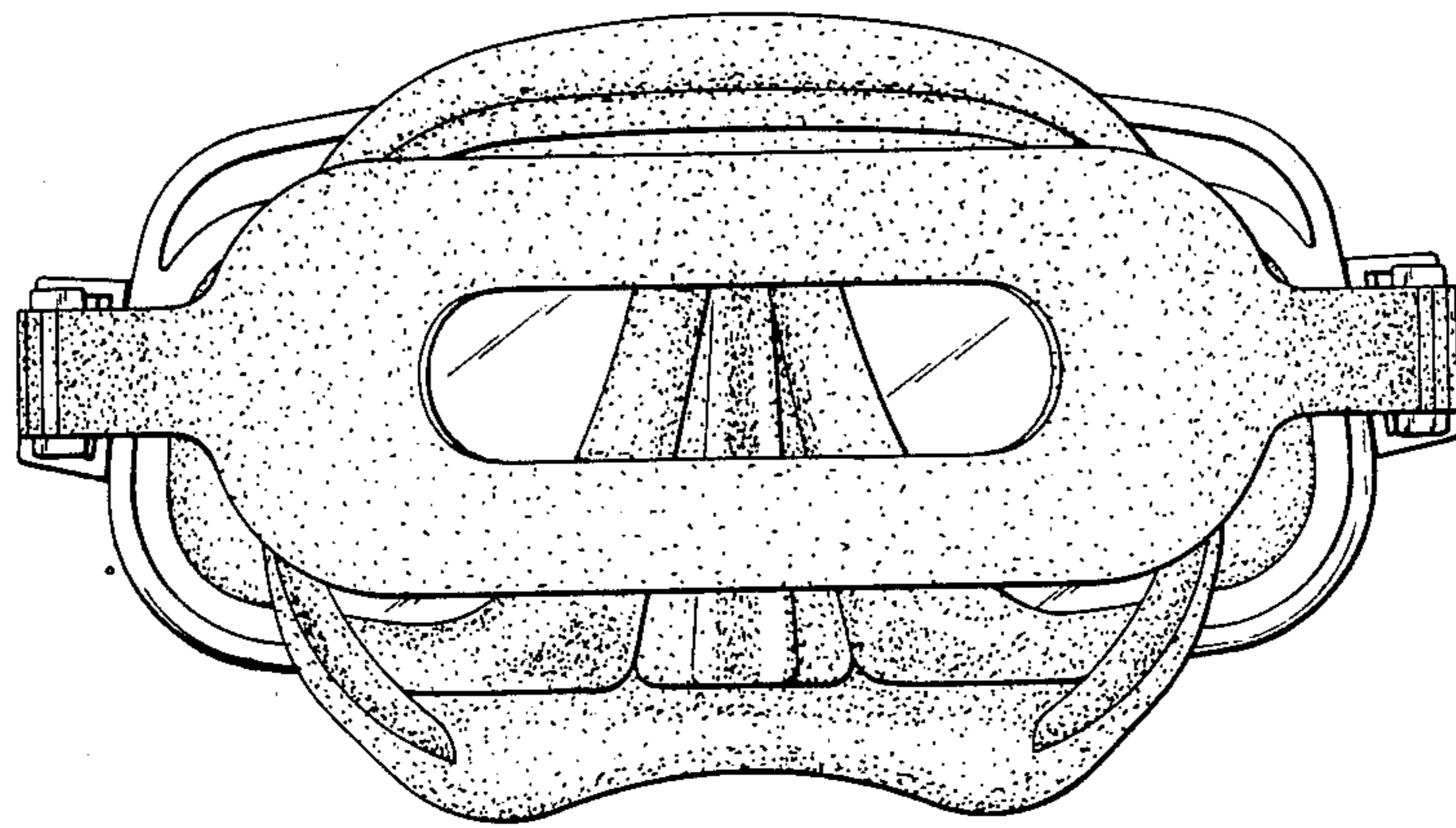


FIG. 3

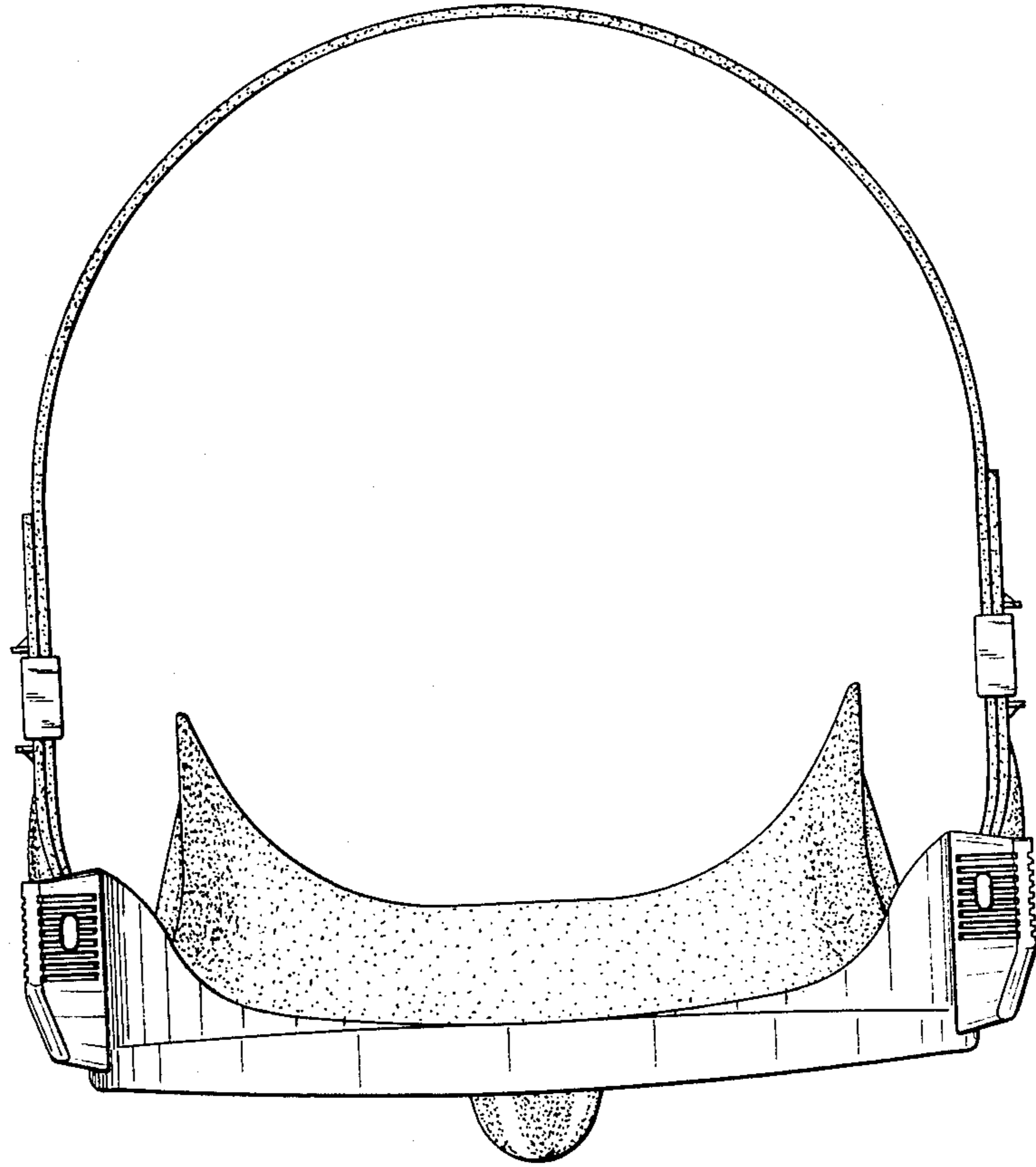


FIG. 4

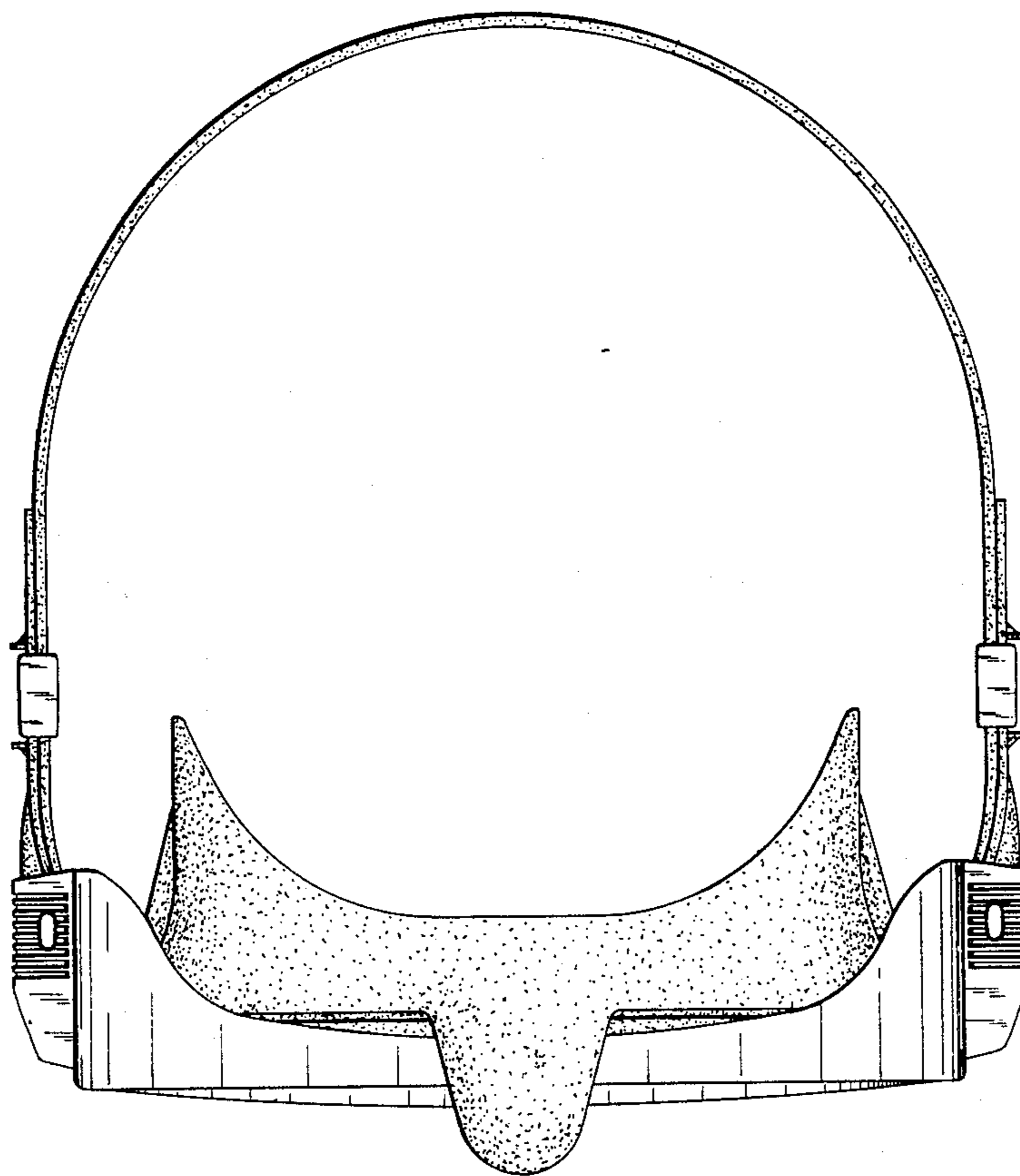


FIG. 5